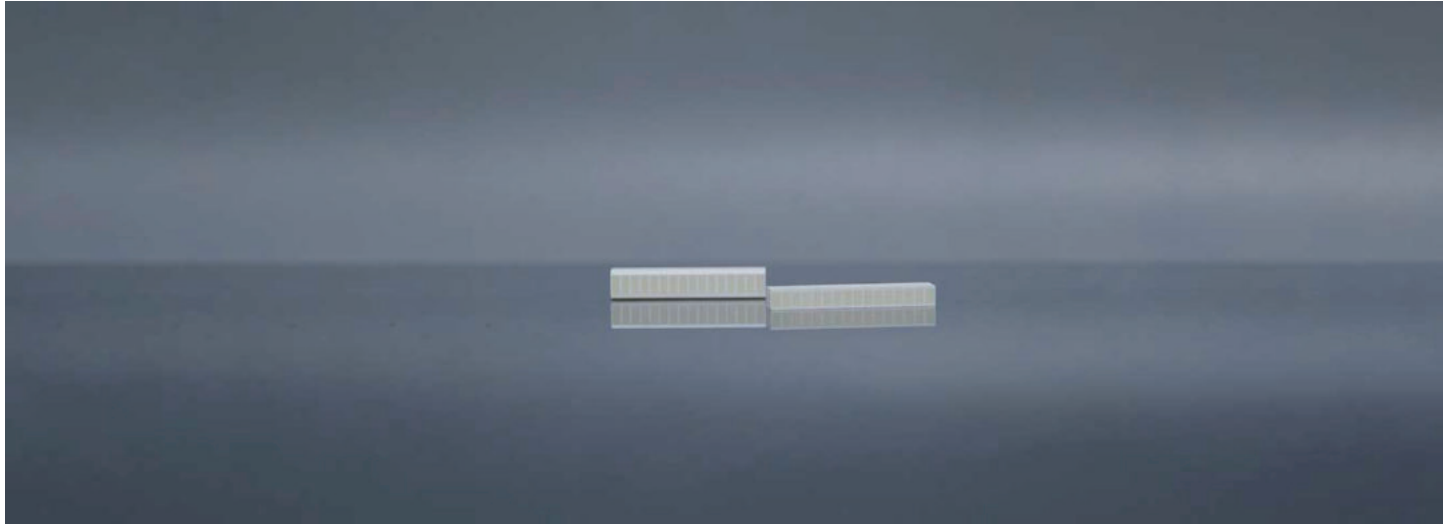


GOS Scintillator Ceramic



DESCRIPTION

GOS ($\text{Gd}_2\text{O}_2\text{S}$, gadolinium oxysulfide) has excellent characteristics such as high light output, high density, short afterglow, etc. GOS ceramic belongs to hexagonal system structure. It exhibits chemical inertness. GOS doped with rare earth ion has relatively high light output and extremely low afterglow. The emission peaks range from 480 to 900 nm **matches well** with spectral sensitivity of silicon photodiodes. It has been widely used for purposes such as CT scanners, security devices and non-destructive testing.

FEATURES

- High light output
- Low afterglow
- High density
- High X-ray absorption efficiency
- Chemical inertness

APPLICATIONS

- X-ray CT
- X-ray microscope
- CT scanners
- Neutron detection

PARAMETERS

MATERIAL PROPERTIES

Property	Value
Materials	$\text{Ge}_2\text{O}_2\text{S}$
Density (g/cm^3)	7.34
Crystal structure	Hexagonal
Lattice parameters	$a=b=3.85827\text{\AA}$
Hygroscopicity	No
Cleavage plane	No
Solubility ($\text{g}/100\text{gH}_2\text{O}$)	N/A



GOS Scintillator Ceramic

SCINTILLATOR PROPERTIES

Property	Value
Wavelength(Max. emission) (nm)	510
Wavelength range (nm)	400-900
Decay time	5.5
Wide-Gap (eV)	4.6-4.8
Light output(photons/MeV)	27000
X-ray attenuation coefficient (cm ⁻¹)	52 at 70 keV 0.80 at 500 keV
Afterglow (%)	<0.01
Radiation damage	-3

SPECTRA

